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AIChE

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If you're planning to be in San Francisco, stop by the demonstration area. Try out AIChExchange, give us your feedback, and take home a free disk that will enable you to access the bulletin board through a user-friendly graphic interface. Directions on how to access AIChExchange, will be available on-site, so you can spend more time exploring when you get home.

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AIChE Journal (ISSN 0001-1541) is published monthly by the American Institute of Chemical Engineers, 345 E. 47th St., New York, NY 10017. Manuscripts should be submitted to Editor Matthew V. Tirrell at the Dept. of Chemical Engineering and Materials Science, University of Minnesota, Minneapolis, MN 55455, phone (612) 625-5823, fax (612) 626-1686. The statements and opinions in the *AIChE Journal* are those of the contributors, and AIChE assumes no responsibility for them. Annual subscription rates: \$395 for nonmembers, \$60 for members, and \$30 for student members; outside U.S., add \$60 for postage. Single copies: \$40; outside U.S., add \$5 for postage. Second-class postage for domestic and air mail postage for foreign mailing paid at New York, NY and additional mailing offices. Copyright 1994 by the American Institute of Chemical Engineers. Subscribers are requested to give prompt notification of any change of address. Postmaster: Send changes of address to *AIChE Journal*, 345 East 47th St., New York, NY 10017.

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